	Туре	L#	Hits	Search Text	DBs	Time Stamp	C o m m	ef in	Er ro rs
1	BRS	L1	2	"20020030178"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 10:16			0
2	BRS	L8	13259	etch\$3 same polyimide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:04			0
3	BRS	L15	471	(NaOH or KOH or LiOH or ((sodium or potassium or lithium or tetramethylammonium or tetraethylammonium or quaternary) adj hydroxide)) same 8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:21			0
4	BRS	L22	0	(diol or triol) same 15	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 10:29			0
5.	BRS	L29 	4	(diol or triol) same 8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:53	,		0
6	BRS	L36	0	(1,3-propanediol or 2,3-butanediol or 1,4-butanediol or 1,5-pentanediol) same 8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 10:27		,	0
7	BRS	L43	74571	etch\$3 same (polyimide or polyamic or photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 10:26			0
8	BRS	L50	1	(1,3-propanediol or 2,3-butanediol or 1,4-butanediol or 1,5-pentanediol) same 43	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:53			

BEST AVAILABLE COPY

	Туре	L#	Hits	Search Text	DBs	Time Stamp	0 E E e	ef	Er ro rs
9	BRS	L57	16	(diol or triol) and 15	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:02			0
10	BRS	L64	555	(manufacturing with "wiring board") same etch\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:04		-	0
11	BRS	L71	110	64 and polyimide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:06			0
12	BRS	L78	48	71 and @pd<=20000712	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11: 44			0
13	BRS	L85	7	"5209815"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB				0
14	BRS	L92	14	"8805813"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:43			0
15	BRS	L99	2478	(polyimide with (photoresist or resist)) same etch\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:43			0
16	BRS	L106	1767	99 and @pd<=20000712	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:54			0

BEST AVAILABLE COPY

	Туре	L#	Hits	Search Text	DBs	Time Stamp	C o m m	r D ef in	Er
17	BRS	L113	482	106 and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:51			0
18	BRS	L120	1367	etch\$3 with resin with polyimide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:11			0
19	BRS	L127	49	(NaOH or KOH or LiOH or ((sodium or potassium or lithium or tetramethylammonium or tetraethylammonium or quaternary) adj hydroxide)) same 120	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:53			0
20	BRS	L134	0	(diol or triol) same 127	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:06			0
21	BRS	L141	0	(1,3-propanediol or 2,3-butanediol or 1,4-butanediol or 1,5-pentanediol) same 127	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 11:54			0
22	BRS	L148	1	(1,3-propanediol or 2,3-butanediol or 1,4-butanediol or 1,5-pentanediol) and 127	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:37			0
23	BRS	L155	37	127 and @pd<=20000712	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:23			0
24	BRS	L162	0	glycol same 127	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:06			0

BEST AVAILABLE COPY

	Туре	L#	Hits	Search Text	DBs	Time Stamp	o m m	ın	Er ro
25	BRS	L169	6	glycol and 127	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:06			0
26	BRS	L176	0	(etch\$3 with resin with polyimide) same glycol	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:11			0
27	BRS	L183	40	(NaOH or KOH or LiOH or ((sodium or potassium or lithium or tetramethylammonium or tetraethylammonium or quaternary) adj hydroxide)) same (wash\$3 or etch\$3 or dip\$4) same polyamic	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:22			0
28	BRS	L190	33	183 and @pd<=20000712	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 12:23			0
29	BRS	L197	11	(1,3-propanediol or 2,3-butanediol or 1,4-butanediol or 1,5-pentanediol or glycol) same etch same (polyimide or polyamic)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 13:08			0
30	BRS	L204	5	(1,3-propanediol or 2,3-butanediol or 1,4-butanediol or 1,5-pentanediol or glycol) same etch same (polyimide or polyamic) same (resist or photoresist).	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/28 13:08			0

SEST AVAILABLE COPY